

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	Hada et al.
Appl. No.	:	10/563,705
Filed	:	January 5, 2006
For	:	RESIST COMPOSITION, LAMINATE, AND METHOD FOR FORMING RESIST PATTERN
Examiner	:	Chu, John S Y
Group Art Unit	:	1752

**SECOND (CORRECTED) PRELIMINARY AMENDMENT AND RESPONSE TO NOTICE
OF NON-COMPLIANT AMENDMENT**

Mail Stop Amendment

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

Preliminary to examination on the merits, please amend the above-captioned U.S.
National Phase Application as follows:

Amendments to the Specification begin on page 2 of this paper.

Remarks begin on page 3 of this paper.